

L Number	Hits	Search Text	DB	Time stamp
1	7	(("5395790") or ("5492858") or ("5541436") or ("6054393") or ("6057208") or ("6129091") or ("6165854")).PN. ("pad oxide") with (nitride) with (oxynitride or "oxy nitride" or SiON)	USPAT; US-PGPUB	2002/10/20 19:20
4	45	("water spot" or "water spots" or "water mark" or "water marks") and (oxynitride or "oxy nitride" or sion)	USPAT; US-PGPUB	2002/10/20 20:04
5	34	oxynitride SAME (RTA or "rapid thermal anneal" or plasma)	USPAT; US-PGPUB	2002/10/20 20:05
-	1692	(oxynitride SAME (RTA or "rapid thermal anneal" or plasma)) and photoresist and nitride and oxide	USPAT; US-PGPUB	2002/07/23 13:07
-	769	((oxynitride SAME (RTA or "rapid thermal anneal" or plasma)) and photoresist and nitride and oxide) and trench	USPAT; US-PGPUB	2002/07/23 13:07
-	343	((oxynitride SAME (RTA or "rapid thermal anneal" or plasma)) and photoresist and nitride and oxide) and trench	USPAT; US-PGPUB	2002/10/16 09:36
-	71	((oxynitride SAME (RTA or "rapid thermal anneal" or annealing)) and photoresist and nitride and oxide) and trench	USPAT; US-PGPUB	2002/10/16 10:06
-	92	((oxynitride or ONO or "oxy nitride") SAME (RTA or "rapid thermal anneal" or annealing)) and photoresist and nitride and oxide) and trench	USPAT; US-PGPUB	2002/10/16 10:09
-	265	(oxynitride or ONO or "oxy nitride") SAME (dense or denser or densified or densifying)	USPAT; US-PGPUB	2002/10/16 10:11
-	116	(oxynitride or ONO or "oxy nitride") WITH (dense or denser or densified or densifying)	USPAT; US-PGPUB	2002/10/16 10:14
-	45	((oxynitride or ONO or "oxy nitride") WITH (dense or denser or densified or densifying)) and (RTP or RTA or anneal or annealing)	USPAT; US-PGPUB	2002/10/16 10:41
-	6	("5258332" "5578518" "5719085" "5976948" "6083808" "6180466").PN.	USPAT	2002/10/16 11:14
-	340	((oxynitride or ONO or "oxy nitride") SAME (RTA or "rapid thermal anneal" or annealing)) and (clean or wet or HF or BOE)	USPAT; US-PGPUB	2002/10/16 11:46
-	377	((oxynitride or "oxy nitride" or ONO) WITH (anneal or annealing or RTP or thermal)) same (oxygen or nitrogen)	USPAT; US-PGPUB	2002/10/16 11:52
-	144	((oxynitride or "oxy nitride" or ONO) WITH (anneal or annealing or RTP or thermal)) same (oxygen or nitrogen)) and (ARC or photoresist)	USPAT; US-PGPUB	2002/10/16 11:49